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FJ,UORTNATION OF OXIDES OF URANIUM AND THORIUM BY AMMONIUM HYDROGENFLUORIDE

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SUMMARY

UO₂, U₃O₈ and ThO₂ were fluorinated by NH₄HF₂ either alone or in conjunction with NH_IF at room temperature to ${\rm [NH_4\,]_4\,UF_8\,.2H_2O}$, ${\rm [NH_4\,]_4\,VO_2\,F_5\,.H_2O}$ and ${\rm [NH_4\,]_4\,ThF_8\,.2H_2O}$ respectively. The TG/DTA and powder XRD techniques were employed **t0** study the thermal decomposition of these compounds and identify the final residues as UF_4 , U_2F_2 .2H₂O and ThF₄. This appears to be a simple route to the tetrafluorides.

INTRODUCTION

 $NH₄ HF₂$ has been used [1-3] as a fluorinating agent at room temperature or close to room temperature to prepare fluoro and oxyfluoro anionic compounds of V(III), V(V), Nb(V) and Ta(V). More recently [4,5] it has found application in introducing fluorine in place of oxygen in complex oxides such as 1,2,3 superconducting oxide $YBa₂Cu₃O₆₊₅$. Sanlaville [6] has shown that reaction between ammonium hydrogenfluoride and oxides of uranium can be used to prepare different fluorides/ oxyfluorides. The mechanism of the reaction was not investigated. In this

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communication, we report the reaction of ammonium hydrogenfluoride with three oxides, $\mathsf{viz.}_f$ $\mathsf{Uo}_2^{}$, $\mathsf{U}_3^{}$ (and ThO,.

EXPERIMENTAL

The materials employed in this study are: UO₂ and ThO₂ of nuclear grade and U₃O₈ with an oxygen to metal ratio of 2.655, as determined according to the technique described by Menilly and Chikalla [7]. The NH₄HF₂ is of BDH IR quality. All the reactions were conducted by intimate grinding together of the constituents in polythene bags. The TG/DTA equipment was a ULVAC SINKU RIKO TGD model 7000RHP. The heating/cooling rate was $8K.\text{min}^{-1}$, the atmosphere is static air and the sample size is 30mg. XRD powder pattern was run using a nickel filtered $Cu-K_{\alpha}$ radiation.

Reaction With UO₂

A mechanical mixture of UO₂ and NH₄HF₂ in 1:4 proportion was mixed for about 15 minutes. The powder XRD pattern of the resultant mixture taken immediately shows no reaction between the constituents. However, on keeping the mixture for about 2 hours the colour of the mixture changed from black to green and showed a total absence of NH_1HF_2 and UO₂ peaks in the XRD pattern showing reaction between the two reactants. The products, however, were not crystalline. The product was dried at 1OOC and its XRD pattern, which became crystalline agreed reasonably well with that reported [8] for $[NH_4]_4$ UF_g. The TG/DTA runs of the mixture are shown in figure 1. While the TG shows three clear, though overlapping steps, the DTA exhibits three endotherms with 1:2:1 areas. The thermal data are summarised in Table 1. The residue in both TG/DTA at 400C is UF_,. All the thermal data may be quantitatively explained in terms of the following steps.

$$
UO2 + 4NH4 HF2 \xrightarrow{RT} [NH4]4 UF8 . 2H2O \xrightarrow{(1)}
$$

\n
$$
[NH4]4UF8 . 2H2O \xrightarrow{80°C} [NH4]4UF8 + 2H2O \xrightarrow{(2)}
$$

\n
$$
[NH4]4UF8 \xrightarrow{NH4]3UF7 + NH4F \xrightarrow{(3)}
$$

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$$
[NH4]3UF7 \xrightarrow{TH4]} [NH4]UF5 + 2NH4F \xrightarrow{(4)}
$$

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$$
[NH4]UF5 \xrightarrow{UF4} + NH4F \xrightarrow{(5)}
$$

Fig.1. Simultaneous TG/DTA of (MH) UF in air.

SUMMARY OF TG/DTA RESULTS

The first equation represents the reaction between the reactants. The second step denotes dehydration at IOOC which makes the material crystalline as was mentioned above.. The three steps in TG and DTA correspond to equations (3) , (4) and (5) .

Reaction with $U_2 O_0$

The black oxide, $NH_{1}HF_{2}$ and $NH_{1}F$ were mixed in the proportion 0.33:2:1 for about half-an-hour. The product was green coloured and the XRD pattern of the product agreed well with that reported [9] for $[NH_L]_3UO_2F_5H_2O$ without any left over reactants. The TG/DTA runs of this compound are given in figure 2 and the thermal data summarised in Table 1. The TG shows two steps consistent with loss of three moles of NH_.F in the first step and loss of one mole of water in the second. The corresponding DTA shows a strong peak for the first followed by a weak one for the second. The final product in both the cases is UO₂F₂ which readily picks up moisture to the dihydrate. In this case since the uranium oxide is non-stoichiometric, it is not possible to balance the equation for the reaction (1). However, the course of reaction and thermal degradation can be represented as follows:

1/3U₃O₂ + 2NH₄ HF₂ + NH₄ F $\xrightarrow{\text{RT}}$ (NH₄]₃UO₂ F₅ .H₂O (6) $\text{[NH}_{1, 1, 00, F_{5} \cdot H_{2} \cdot H_{2} \cdot H_{3} \cdot H_{4} \cdot H_{5} \cdot H_{6} \cdot H_{7} \cdot H_{8} \cdot H_{9} \cdot H_{10} \cdot H_{11} \cdot H_{12} \cdot H_{13} \cdot H_{14} \cdot H_{15} \cdot H_{16} \cdot H_{17} \cdot H_{18} \cdot H_{19} \cdot H_{10} \cdot H_{10} \cdot H_{11} \cdot H_{10} \cdot H_{11} \cdot H_{10} \cdot H_{11} \cdot H_{10} \cdot H_{11} \cdot H_{10} \cdot H_{11}$ $\mathsf{UO}_2\mathsf{F}_2\cdot\mathsf{H}_2\mathsf{O}$ (8) $\longrightarrow \mathsf{UO}_2\mathsf{F}_2$ + $\mathsf{H}_2\mathsf{O}$ (8)

The thermal data given in Table 1 are consistent with this scheme.

Reaction with ThO₂

The reaction between ThO₂ and NH₄HF₂ in 1:4 proportion was attempted as in the case of $UO₂$. The product after keeping for two hours at room temperature did not show the presence of starting materials. Its XRD pattern agrees with that reported by Ryan [10] for $[NH, 1]$ ThF, but for the total absence of the reported reflection with d=8.15A. The TG/DTA of the compound are given in figure 3. The TG shows three steps, the first two with loss of 2NH,F each and the third with loss of 2H₂O with simultaneous hydrolysis. The corresponding DTA shows three endotherms. Tf the compound is heated at 100C the product is assumed to be $[NH_{\mu}]_2$ ThF₆.2H₂0, the thermal data in Table 1 can be summarised in terms of the following equations:

A doubt arises whether water absorbed by ammonium hydrogenfluoride is responsible for the so called solid state reactions that take place with ease at room temperature. In order to confirm this, the reaction with UO₂ was performed with ammonium hydrogenfluoride dried by heating at 80C and further dried over $P_2^oS_5^o$ overnight. No reaction took place over Zhrs. The mixture was then kept at room temperature over P 0 in a desiccator for 24hrs under
2 5 dry condition. The reaction did take place under these conditions showing that even in the absence of moisture, reaction takes place.

It is worth noting that reaction of ammonium hydrogenfluoride was very slow with U(IV) compared to that with U(VI) and Th(IV). Similarly, removal of water of reaction was more difficult in last two cases compared to $U(IV)$.

Both uranium and thorium are in +4 oxidation state in their dioxides and hence the products of fluorination of these oxides, $[NH_{\mu}]$, U/Th F_{μ} , are also in the same oxidation state. In the non-stoichiometric oxide U_3O_8 , however, uranium is in +6 oxidation state with oxygen vacancies in the lattice and hence the product of fluorination, [NH] UO F , is in $+6$ oxidation state.
 $\frac{4}{3}$ $\frac{3}{2}$ $\frac{2}{5}$

CONCLUSTON

From the foregoing, we find that NH_4 HF reacts with $\frac{1}{2}$ U_0 / Tho₂ to give [NH₄]₄U/ThF_a compounds while it reacts with U_{3}° (o give [NH₄]₃UO₂F₅. These three compounds, on heating to about 400C give U/ThF₁ and UO₂F₂.2H₂O.

Tt may be added that the usual mode of preparation of UF₄ from UO₂ is by reaction with anhydrous HF at about 400C. It appears that the present method of using NH_LHF_2 for making UF_{λ} is simpler.

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REFERENCES

- 1 B.R.Wani, U.R.K.Rao, K.S.Venkateswarlu and A.S.Gokhale, Thermochimica Acta, 58 (1982)87.
- 2 U.R.K.Rao, K.S.Venkateswarlu and B.N.Wani, J Fluorine $Chem.$, 31 (1986) 29.
- 3 B.N.Wanj, U.R.K.Rao and K.S.Venkateswarlu, National Symp. on Unusual Valency States in Coordination Compounds, Bombay **(1987).**
- 4 U.R.K.Rao, A.K.Tyagi, S.J.Patwe and R.M.Iyer, Pramana, J Phvs. x **(1988)** L79.
- 5 U.R.K.Rao, A.K.Tyagi, S.J.J?atwe, R.M.Xyer, M.D.Sastry, R.M.Kadam, Y.Babu and A.G.I.Dalvi, Solid Stat Commun., fj7, 4 (1988) 385.
- 6 J. Sanlaville, Proc 2nd United Nations Int Conf on Peaceful Uses of Atomic Energy, Geneva 4 (1958) 103.
- 7 C.E.Menilly and T.D.Chikalla, J_Nucl_Mat., 39 (1971) 77
- 8 R.Benz, R.M.Douglas, F.H.Kruse and R.A.Penneman, Inorg Chem., 2 (1963) 799.
- 9 A.E.Baker and H.M.Handler, Inorg Chem., 1, (1962) 127
- 10 Ryan, Los Alamos Scientific Lab, Los Alamos, NM, USA, Quoted in Powder XRD File ASTM Card No 23-28.